

Reg No.: _____

Name: _____

APJ ABDUL KALAM TECHNOLOGICAL UNIVERSITY

B.Tech Degree S3 (R) (FT/WP) Examination November 2025 (2024 Scheme)

Course Code: PCECT302**Course Name: SOLID STATE DEVICES**

Max. Marks: 60

Duration: 2 hours 30 minutes

PART A*(Answer all questions. Each question carries 3 marks)*

		CO	Marks
1	Distinguish between lattice scattering and ionized impurity scattering	CO2	(3)
2	For a semiconductor under thermal equilibrium, effective densities of states in the conduction band and valence bands are given as $N_c = 10^{19} \text{cm}^{-3}$ and $N_v = 5 \times 10^{18} \text{cm}^{-3}$, Energy band gap is 2 eV. Calculate the intrinsic carrier concentration at 300K.	CO1	(3)
3	Define base width modulation and its impact on collector and base currents	CO3	(3)
4	Draw and explain current components in a p-n-p transistor	CO3	(3)
5	Distinguish between electron affinity and work function	CO4	(3)
6	Differentiate Ohmic and rectifying contacts	CO4	(3)
7	Define Sub threshold conduction in MOSFET	CO5	(3)
8	Explain the need for scaling?	CO5	(3)

PART B*(Answer any one full question from each module, each question carries 9 marks)***Module -1**

9	a) Illustrate the Generation and recombination mechanisms of excess carriers in semiconductors.	CO1	6
	b) An n-type Si sample with $N_D = 10^{15} \text{cm}^{-3}$ is steadily illuminated such that $g_{op} = 10^{21} \text{EHP/cm}^3\text{s}$. If $\tau_n = \tau_p = 1 \mu\text{s}$ for this excitation, calculate the separation in the quasi-Fermi levels ($E_{Fn} - E_{Fp}$).	CO1	3

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| 10 | a) Derive the expression for diffusion current density with suitable sketch. | CO2 | 9 |
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Module -2

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| 11 | a) Derive the expression for the built-in potential of a PN junction under thermal equilibrium. | CO3 | 5 |
| | b) An abrupt silicon PN junction has $N_A=10^{17} \text{ cm}^{-3}$ on the p-side and $N_D=10^{15} \text{ cm}^{-3}$ on the n-side. The relative permittivity of Si is 11.8. | CO3 | 4 |
| | 1. Calculate the built-in voltage (V_0). | | |
| | 2. Width of depletion region (W) | | |
| 12 | a) Derive the ideal diode equation with a neat sketch. | CO3 | 9 |

Module -3

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| 13 | a) Draw and explain the C-V Characteristics of an Ideal MOS capacitor | CO4 | 6 |
| | b) Derive the expression for the threshold voltage of MOS Capacitor. | C04 | 3 |
| 14 | a) Draw and explain the energy band diagrams, of an ideal MOS capacitor under equilibrium, and inversion conditions. | CO4 | 5 |
| | b) An nMOS transistor has $W/L=4/2$, gate oxide thickness $40 \text{ \AA}$, Mobility of electrons $180 \text{ cm}^2/\text{Vsec}$. The threshold voltage is 0.4 V , relative permittivity of gate oxide $\epsilon_{ox}=3.9$. Calculate the drain current when | CO4 | 4 |
| | i) $V_{gs} = 1.5 \text{ V}$, $V_{ds} = 1.8 \text{ V}$ | | |
| | ii) $V_{gs} = 1.5 \text{ V}$, $V_{ds} = 0.3 \text{ V}$ | | |

Module -4

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| 15 | a) Explain drain induced barrier lowering | CO5 | 3 |
| | b) Distinguish between constant voltage scaling and constant field scaling | CO5 | 6 |
| 16 | a) Draw and explain the structure and working of Fin FET. | CO5 | 6 |
| | b) Explain channel length modulation of MOSFET | C05 | 3 |
